



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

: Confirmation No. 6339

Kazufumi SATO et al.

: Docket No. 2003_1687

Serial No. 10/716,632

: Group Art Unit 1752

Filed November 20, 2003

: Examiner Yvette C. Thornton

POSITIVE-WORKING PHOTORESIST
COMPOSITION

Mail Stop: Amendment

RESPONSE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Official Action dated June 29, 2005, please amend the present application as follows: